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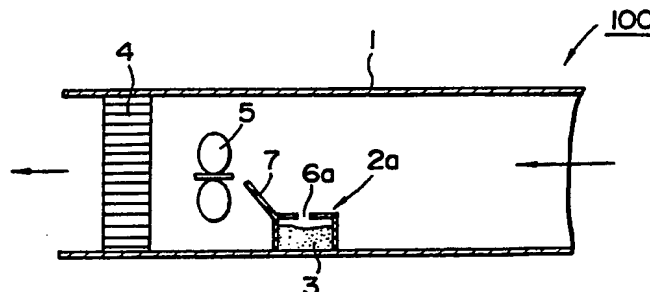
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(54) Ozone decomposing material

(57) An ozone decomposing material comprises an ozone decomposing agent and a support material for supporting the ozone decomposing agent by adsorption. Ozone decomposing apparatus comprises the above ozone decomposing material (4) and ozone decomposing agent supply means (2a, 6a, 5) for supplying the ozone decomposing agent to the support material by which the ozone decomposing agent is adsorbed.

FIG. 2



At least one drawing originally filed was informal and the print reproduced here is taken from a later filed formal copy.

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